The capacitive properties of amorphous manganese dioxide electrodeposited on different thermally-treated carbon papers

Hua Zhao, Gaoyi Han*, Yunzhen Chang, Miaoyu Li, Yanping Li

Institute of Molecular Science, Key Laboratory of Chemical Biology and Molecular Engineering of Education Ministry, Shannxi University, Taiyuan 030006, China

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ABSTRACT

The surface structure of the commercial carbon paper (CP) has been modified through thermal treatment, and then MnO2 was electrodeposited on the thermally-treated carbon paper (TTCP) by cyclic voltammetry (CV) method in the phosphate buffer solution (PBS, pH 9.18) containing KMnO4. The obtained samples were characterized by X-ray diffraction (XRD), X-ray photoelectron energy spectroscopy (XPS) and scanning electron microscopy (SEM). The results showed that the phase of the obtained MnO2 was amorphous, and that the morphology of the MnO2 deposited on the substrates was influenced strongly by the substrates. The capacitive properties of MnO2 deposited on the carbon substrates were investigated by CV, galvanostatic charge/discharge, electrochemical impedance spectroscopy technique. It was found that the specific capacitance of MnO2 deposited on the optimum TTCP can reach to 749 F g−1 based on the charge/discharge measurement, which was far larger than that on the CP (345 F g−1).

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1. Introduction

Electrochemical capacitors as electrical energy storage devices have attracted a lot of attention in many fields such as hybrid power sources, peak power sources and lightweight electric fuse and so on [1–3] due to their greater power density, higher energy density and longer cycle life [4,5]. Based on the operating mechanisms, electrochemical capacitor can be generally classified into two kinds: one is the double-layer capacitors which depend on the charge-separation at the larger surface of the materials of electrode/electrolyte interface; the other is pseudocapacitors which depend on the Faradic redox reaction of the electrochemically active materials. The materials used in pseudocapacitors usually include metal oxides and conducting polymers. Among the metal oxides, manganese oxide is one of the most promising materials of electrode used in electrochemical capacitors because of its low cost, satisfactory capacitive behavior and environmental compatibility.

Up to date, many methods including co-precipitation [6], thermal decomposition [7], sol–gel process [8,9], hydrothermal process [10,11] and electrodeposition [12–18] have been developed to prepare manganese oxides for applications in capacitors. Electro-synthesis is a very promising method for fabrication of thin oxide films for catalytic, electrochemical and biomedical applications because of the easy deposition on substrates without further separation. The process of electrodeposition includes anodic synthesis and cathodic synthesis: in anodic deposition, the Mn2+ is oxidized into MnO2 while in the cathodic process MnO4− is reduced into MnO2. The deposition of MnO2 on different substrates through anodic process has been reported by many literatures [13–17], during which Na2S2O4 aqueous solution is usually used as electrolyte. However, the deposition of MnO2 through cathodic process from MnO4− is much less than that of anodic process. Recently, Wei et al. [18] have deposited MnO2 on stainless steel in Na2S2O4 solution by using the cathodic process, and the specific capacitance (Csc) of MnO2 is measured to be about 353 F g−1.

It is well known that the manganese oxide exhibits inherent poor electronic conductivity and that the electrolyte is difficult to penetrate into the inner layer of thick films [16]. The specific capacitance of MnO2 decreases with the increase of the film’s thickness and the values of Csc for MnO2 films reported in literatures [19,20] are usually in the range of 100–300 F g−1 except that the very thin films of MnO2 (∼4 μg cm−2) exhibit [21,22] a Csc of 700 F g−1. On the other hand, carbon paper (CP) should be an ideal alternative conductive substrate/electrode for the electrochemical deposition of electrochemically active materials. Indeed, compared with metallic substrate, CP is a kind of synthetically thin, lightweight matrix with a relatively larger surface area because of the porous spaces on the micrometer scale [23]. Using three-dimensional CP as substrate, the hierarchically porous conductive composites derived from CP decorated with carbon nanotubes have been fabricated and the capacitive properties also been investigated [24]. Recently, the needle-shaped MnO2 has been deposited on carbon fibers [16]
by using manganese acetate as sources material through anodic synthesis, and the $C_{\text{MnO}_2}$ of $\text{MnO}_2$ is measured to be about 432 F g$^{-1}$.

Therefore, it is interesting to deposit $\text{MnO}_2$ films on the CP in order to obtain a larger supporting amount on unit geometric area. However, the properties of CP are influenced strongly by its surface structure and the oxygen-containing functional groups [25]. The surface modification of the carbons can be usually achieved by electrochemical oxidation, cold plasma treatment and chemical oxidations [26–28], but the method of gaseous oxidation shows less structural damage for carbon [29]. In this paper, the surface of CP is modified by thermal treatment in air, and the different thermally-treated carbon papers (TTP) are used as substrates for the electro-deposition of $\text{MnO}_2$ layer in PBS buffer containing $\text{KMnO}_4$. As a result, this study aims to investigate the influence of the thermal treatment in air on the morphologies and the capacitive properties of $\text{MnO}_2$ deposited on carbon substrates.

2. Experimental

2.1. Reagents and materials

The CP (Toray Composites Inc., Japan) were used directly or after thermal treatment. The commercial CP were thermally treated by two methods: one process was that the CP was heated at 550 °C under atmosphere for 6 h in a muffle furnace and the samples were named as MCP; the other was that the CP was treated in a muffle furnace at 550 °C under atmosphere for 1 h firstly, and then in a muffle furnace at 550 °C for 3 h again after being heated at 1200 °C for 2 h in a tube furnace under Ar atmosphere (MTCP). $\text{KMnO}_4$ and other reagents were of analytical grade and used without further purification.

2.2. Electrodeposition of the $\text{MnO}_2$ on CP and TTP

The PBS solution with a concentration of 0.067 M and pH 9.18 was used as electrolyte. The commercial CP and TTP were cut into rectangular straps with length of 20 mm and width of 3 mm for use. The electrodeposition was carried out on a CHI 660 C electrochemical station by using CV at scan rate of 100 mV s$^{-1}$ using a three electrode system. The PBS solution containing various amounts of $\text{KMnO}_4$ was used as electrolyte, the carbon straps fixed on the copper bar were used as working electrodes, and the Pt foil and saturated calomel electrode (SCE) were used as the counter and reference electrodes, respectively. The optimum experimental procedure was chosen as follows: PBS containing 3.0 mg mL$^{-1}$ of $\text{KMnO}_4$ was used as the electrolyte, and the mass of $\text{MnO}_2$ deposited on the substrates was kept to be about 0.43 mg cm$^{-2}$ based on the geometric area (see supporting materials). The $\text{MnO}_2$ deposited on the CP, MCP and MTCP was defined as CP-$\text{MnO}_2$, MCP-$\text{MnO}_2$ and MTCP-$\text{MnO}_2$, respectively.

2.3. Characterization

The morphologies of the samples were observed on a scanning electron microscope (JSM 6701F) and the X-ray diffraction (XRD) patterns were recorded on a Bruker D8 Advance X-ray diffractometer (Cu Ka) in the 2θ range of 10–80°. X-ray photoelectron spectroscopy (XPS) measurements were performed on an American Thermo-VG Scientific ESCALAB 250XPS system with Al Kα radiation as the exciting source, where the binding energies were calibrated by referencing the C 1s peak (284.6 eV) to reduce the sample charge effect.

The CP straps loaded with $\text{MnO}_2$ were held on the copper rods, a plate of platinum and a SCE electrode were used as working, counter and reference electrode, respectively. The electrochemical measurements were carried out on a CHI660C electrochemical station by using 1.0 M $\text{Na}_2\text{SO}_4$ aqueous solution as electrolyte. The measurements of CV were performed in a potential range between −0.1 and 0.8 V at different scan rates. The galvanostatic charge/discharge curves were recorded at varying current densities with the cutoff voltage of −0.1 and 0.8 V. The electrochemical impedance spectra (EIS) were recorded at open-circuit potential in the frequency ranged from 100,000 to 0.01 Hz with ac-voltage amplitude of 5 mV.

3. Results and discussion

3.1. The characterization of the TTP

Usually, the CP has been thermally treated to modify its surface properties because of its weak hydrophilic ability. According to the XPS spectra, it can be found that the relative content of oxygen atom on the surface of CP, MCP and MTCP is about 1.5, 2.5 and 7.7%, respectively. This demonstrates that the thermal treatment can increase the content of oxygen on the surface of carbon fibers. The increment of oxygen-containing groups on the surface of the CP will increase the hydrophilic ability of the substrates. It is interesting to find that the content of oxygen atom on the surface of MTCP increases obviously, which may be contributed to the thermal treatment at higher temperature (1200 °C) under Ar atmosphere before the thermal treatment at 550 °C under air.

Based on the high resolution XPS spectra, the curve fitting of the XPS peaks has been performed using Gauss–Lorentzian peak shape after performing a Shirley background correction and the results are shown in Fig. 1. The XPS peaks of C1s with a binding energy of 284.6 and 285.1 eV can be attributed to the C=C and C–C bonds, and the fitted peaks with binding energy of 286.4, 287.6 and 289.2 eV are typically assigned to C=O, C≡O and O=C–O functional groups (Fig. 1A), respectively, while the peak located at 291.2 eV is usually assigned the satellite peak (p–p*) of carbon [29,30]. Based on the area of the fitted peak, the relative content of the groups on the surface of the substrates is listed in the Table 1. It is clear that the CP exhibits the most of C=C and C–C bond, but the least of the oxygen-containing groups. However, the relative content of oxygen-containing groups such as C=O, C≡O and O=C–O increases and the content of C–C bond decreases after thermal treatment, indicating that the default of C=C bond in CP can change into oxygen-containing groups during the thermal treatment. Furthermore, the relative content of O=C–O groups on MTCP surface is the most, which may indicate that the pre-treatment at high temperature is favorable to form the carboxylic group.

As shown in Fig. 1B, it is found that the XPS peaks of the O1s are asymmetrical. The CP shows two fitted peaks: one located at 532.4 eV which is corresponding to the carbonyl oxygen atoms in esters, anhydrides and the oxygen atoms in hydroxyls or ethers, and the other at 534.1 eV which is related to the carboxyl group (Fig. 1B–a) according to the literature [30]. Besides the fitted peaks located at 532.4–532.8 eV and 533.9–534.2 eV which are similar to that of CP, in the O1s XPS spectra of MCP and MTCP, a new fitted peak at 531.1–531.4 eV is observed and assigned to the oxygen atom in C=O groups. From the above results, it can be found that the thermal treatment in air can not only increase the oxygen content of the carbon surface but also change the types of oxygen atoms in the oxygen-containing groups.

<table>
<thead>
<tr>
<th>Samples</th>
<th>Relative content of different bonds (%)</th>
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<tbody>
<tr>
<td></td>
<td>C=C</td>
</tr>
<tr>
<td>CP</td>
<td>64.83</td>
</tr>
<tr>
<td>MCP</td>
<td>63.69</td>
</tr>
<tr>
<td>MTCP</td>
<td>63.17</td>
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*Table 1* The relative content of the different bonds on the surface of carbon substrates.
From the SEM images shown in Fig. 2, it can be found that the surface of fibers in CP is coarse (Fig. 2A), and that many strips and striae are observed on the surface of the fibers. However, the surface of the fibers in MCP becomes smoother than that in CP, moreover, many small particles are observed on the surface, which reveals that the surface of the fibers has been changed by thermal treatment (Fig. 2B). It is interesting to find that the surface of the fibers in MTCP becomes coarse again (Fig. 2C) and is much rougher than that of MCP, and that many small holes and flower-like particles are observed on the surface of the fibers. In order to illustrate the changes of the surface area, the double-layer capacities of the TTCP and CP are also determined in 1.0 mol L\(^{-1}\) Na\(_2\)SO\(_4\) aqueous solution (Fig. 2D). It can be found that the CV curves are rectangular-like with the almost symmetric \(l-E\) responses for all the electrodes, which are corresponding to the rapid current response on voltage reversal at each end potential and accord with the ideal capacitive behavior. From the current responses at the same condition (the same scan rate and the same geometric area), it can be found that the MTCP exhibits larger surface area than MCP while the surface area of CP is the smallest. The above results reveal that the thermal treatment can change not only the content of oxygen atom but also the surface structure of the fibers.

The XRD pattern of the MTCP shows a sharp diffraction peak at 25.6° which is corresponding to the C(0 0 2) crystal plane. However, it is surprising to find that only the C(0 0 2) peak has appeared in the XRD patterns of CP-MnO\(_2\), MCP-MnO\(_2\) and MTCP-MnO\(_2\) (Fig. 3A), while the diffraction peaks corresponding to MnO\(_2\) do not appear. At the same time, the MnO\(_2\) powder collected from the substrates shows a broad and weak diffraction peak centered at about 26.7°. Based on the above results, it can be deduced that the synthesized MnO\(_2\) is amorphous. In order to clarify the valence state of Mn, the XPS spectra are recorded and shown in Fig. 3B. From the XPS peaks of Mn2p, it is found that the peaks of Mn2p\(_{3/2}\) and Mn2p\(_{1/2}\) are located at about 642.9 eV and 654.7 eV, the difference between them is about 11.8 eV, indicating that the main product deposited on the carbon substrates is MnO\(_2\) [31]. Furthermore, from the XPS peaks of C1s shown in Fig. 3C, it is found that the MTCP substrate shows the strongest C1s XPS peak, while the sample of MTCP-MnO\(_2\) possesses a weaker XPS peak of C1s than that of MCP-MnO\(_2\). From this phenomenon, it may be deduced that the layer of MnO\(_2\) deposited on MTCP is more continuous and compact than that on the MCP.

The morphologies of MnO\(_2\) deposited on the carbonaceous substrates are observed by SEM and shown in Fig. 4. It can be found...
that the MnO₂ particles with irregular shapes are deposited on the CP surface, and that the sizes of the particles are ranged from 100 to 200 nm. From the inserted figure in Fig. 4A, it is clear that the MnO₂ particles are dispersed on the part surface of the CP, and that MnO₂ particles have not been deposited on the inner fibers of the CP. However, it is found that the surface of the fibers in MCP has been covered by a layer of MnO₂ (Fig. 4B) although many cracks are observed on the films. Furthermore, the inner fibers of MCP have been coated with a layer of MnO₂ besides the outer fibers. The thickness of the films deposited on the fibers is measured to be ranged from 210 to 277 nm based on the edge section of the films (see supporting materials). From the Fig. 4C, it is interesting to find that the film deposited on the MTCP is smooth and continuous except that some parts of the films are damaged. Similar to MnO₂ deposited on MCP, the inner and outer fibers of MTCP are coated by the layer of MnO₂. The film’s thickness on the MTCP is ranged from 190 to 300 nm (see supporting materials). The above results indicate that the thermal treatment has changed the surface properties of the carbon substrates and that the increase of the content of oxygen-containing group will improve the hydrophilic ability and make the continuous MnO₂ layer form on the surface of carbon fibers. It also illustrates that the XPS peak of C1s for MTCP-MnO₂ is weaker than that of MTCP and MCP-MnO₂ because of the continuous MnO₂ film.

To explore the property of these MnO₂ deposited on carbon substrates as materials of electrochemical capacitor, the electrodes are characterized in 1.0 M Na₂SO₄ electrolyte with CV method because...
it is a convenient technique to evaluate the capacitive properties. The CV curves recorded at various scan rates from 10 to 100 mV s⁻¹ for the samples are shown in Fig. 5A–C. It can be seen that the CV curves of the three electrodes at low scan rate of 10 mV s⁻¹ exhibit a symmetrical rectangle-like shape indicating the ideal capacitive behavior. As the scan rate increases, the obvious distortion from the relatively symmetrical rectangle-shape can be observed from the CV curves for the sample of CP-MnO₂. However, it is clear that the distortion from the rectangularity of the CV curves for the sample of MTCP-MnO₂ and MCP-MnO₂ is much less than that for the sample of CP-MnO₂, especially that for MTCP-MnO₂, less distortion from the rectangularity can be observed until the scan rate reaches to 100 mV s⁻¹, indicating much better rate performance due to its finer layer on the carbon fibers.

The \( C_{Sc} \) (F g⁻¹) of the MnO₂ can be obtained by the following equation:

\[
C_{Sc} = \frac{Q}{m \Delta V}
\]

where \( Q \) is the voltammetric charge, \( \Delta V \) the voltage window (0.9 V), and \( m \) the mass of the active material of the electrode. The \( C_{Sc} \) at different scan rates for the three samples is shown in Fig. 5D. At the scan rate of 1 mV s⁻¹, the sample of MTCP-MnO₂ exhibits a much higher specific capacitance (611 F g⁻¹) than that of MCP-MnO₂ (432 F g⁻¹) and CP-MnO₂ (421 F g⁻¹). The \( C_{Sc} \) decreases as the scan rate increases, which is typical characteristic for electrochemically active MnO₂ materials. At the highest scan rate of 100 mV s⁻¹, the electrodes of MTCP-MnO₂, MCP-MnO₂ and CP-MnO₂ can maintain 58%, 68% and 26% of their full capacitance (we set the specific capacitance at 1 mV s⁻¹ as the full capacitance), respectively. Considering the higher \( C_{Sc} \) of MTCP-MnO₂, the residual capacity is still far larger than that of MCP-MnO₂ although the MTCP-MnO₂ has a lower remaining percentage for capacity than that of MCP-MnO₂. This result reveals that the thermal treatment of CP can not only increase the \( C_{Sc} \) but also improve the rate capability of the MnO₂ deposited on it.

Current density is an important factor to determine the capacitive behavior of the as-obtained materials. In order to evaluate the real applicability of our MnO₂ deposited on the carbon substrates, the charge/discharge tests at various current densities are performed and shown in Fig. 6. The \( C_{Sc} \) can be calculated [4] according to Eq. (2)

\[
C_{Sc} = \frac{I \Delta t}{m \Delta V}
\]

where \( I \) is the charge/discharge current density with a unit of A g⁻¹, \( m \) the mass with a unit of g, \( \Delta t \) the charge or discharge time with a unit of s, and \( \Delta V \) the potential during the charge or discharge process. Normally, the discharge process is used to estimate the \( C_{Sc} \) value. Therefore, the \( C_{Sc} \) values of CP-MnO₂, MCP-MnO₂ and MTCP-MnO₂ are calculated to be about 556, 676 and 749 F g⁻¹ respectively at a discharged current density of 1.0 A g⁻¹. The relationship between the \( C_{Sc} \) and discharged current density is shown in Fig. 6D. It is found that the \( C_{Sc} \) value decreases with the increment of the current density for all the samples, and that the \( C_{Sc} \) for the CP-MnO₂, MCP-MnO₂ and MTCP-MnO₂ is about 267, 411 and 467 F g⁻¹ at the current density of 10 A g⁻¹. Furthermore, a 37% decrease of the \( C_{Sc} \) value for MTCP-MnO₂ is observed with the increase of discharge current density from 1 A g⁻¹ to 10 A g⁻¹, which is smaller than that of MCP-MnO₂ (39%) and CP-MnO₂ (52%). From the repeated charge/discharge curves (5 A g⁻¹) shown in Fig. 6E, it is also found that the sample of MTCP-MnO₂ exhibits larger \( C_{Sc} \) value than that of CP-MnO₂ and MCP-MnO₂, and has the smaller deviation from the cutoff potential during the process, which indicates that MTCP-MnO₂ has better capacitive property.

Fig. 7A shows the Nyquist plots for the MnO₂ deposited on the different carbon substrates, a depressed semicircle (Fig. 7B) in the high-frequency range corresponding to the charge-transfer
Fig. 6. The discharge curves at different current densities of CP-MnO₂ (A), MCP-MnO₂ (B) and MTCP-MnO₂ (C), and the plots the specific capacitance versus the discharge current densities (D) and the repeated charge/discharge curves (E) for CP-MnO₂ (a), MCP-MnO₂ (b) and MTCP-MnO₂ (c).

Fig. 7. Nyquist plots (A) and the EIS in high-frequency region (B), the plots of the specific capacitance versus the frequency (C) and the relationships between the specific capacitance and the cyclic numbers (D) of the electrodes (a) CP-MnO₂, (b) MCP-MnO₂ and (c) MTCP-MnO₂.
resistance, and a straight sloping line in the low-frequency range corresponding to the diffusive resistance. The line in the low-frequency range for CP-MnO₂ exhibits a smaller slope than that for MCP-MnO₂ and MTCP-MnO₂, indicating that CP-MnO₂ has a larger diffusive resistance. However, MTCP-MnO₂ has lower charge transfer resistance and diffusive resistance compared with CP-MnO₂ and MCP-MnO₂, confirming further the superior capacitive behavior of the sample of MTCP-MnO₂ [32].

Fig. 7C presents the \( C_{sc} \) obtained from EIS for the electrodes based on the following equation [33]:

\[
C_{sc} = -\frac{1}{2\pi f m Z'}
\]

(3)

Here, \( C_{sc} \) is the specific capacitance, \( f \) the frequency, \( Z' \) the imaginary part of EIS and \( m \) the mass of active material in the cell. The \( C_{sc} \) of all the capacitors decreases with the increase of the frequency and behaves like a pure resistance in high-frequency region, which reveals that the electrolyte ions cannot be intercalation/deintercalation into the MnO₂ layer. It is also found that MTCP-MnO₂ exhibits a higher \( C_{sc} \) at low frequency range compared with CP-MnO₂ and MCP-MnO₂, which is consistent with the results obtained from CV and charge/discharge data. It should be noted that the specific capacitances values of the capacitor cells at 0.01 Hz are deviated from those obtained from CV and charge/discharge test, which is mainly due to the different testing systems applied.

As the service life is a very important factor for the electrochemical capacitors' electrodes, the stability of the electrodes has been evaluated by using CV method at a scan rate of 50 mV s\(^{-1}\) and the results are shown in Fig. 7D. It can be found that the \( C_{sc} \) of MnO₂ deposited on CP increases slightly after it decreases initially, but the \( C_{sc} \) of MnO₂ deposited on MCP and MTCP decreases with the increase of the cyclic number, and the decreasing rate on MTCP is fast at the beginning but slow later. The \( C_{sc} \) retains 86.3% and 84.8% of the initial capacitance for MnO₂ deposited on MCP and MTCP after 1100 cycles respectively. Considering the fact that the MnO₂ deposited on the MTCP exhibits the largest \( C_{sc} \), the retained value of capacitance is far larger than that on CP and MCP although only 84.8% of the specific capacitance is retained.

4. Conclusions

The amorphous MnO₂ has been deposited on the TTPC through CV method in the PBS solution containing KMnO₄. The morphology and capacitive properties of MnO₂ are influenced strongly by the substrates. The MnO₂ deposited on the MTCP substrate exhibits a \( C_{sc} \) of 749 F g\(^{-1}\) based on the charge/discharge measurement. The electrochemical measurements also show that the MnO₂ deposited on MTCP possesses a high stability and excellent capacitive properties at high scan rate.

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